

2823  
8021

THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Patricia B. Smith, et al.

Docket No: TI-25250

Serial No: 09/199,829

Conf. No: 4119

Examiner: Julio J. Maldonado

Art Unit: 2823

Filed: 11/25/1998

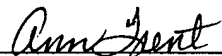
For: HYDROGEN PLASMA PHOTORESIST STRIP AND POLYMERIC RESIDUE  
CLEANUP PROCESS FOR OXYGEN-SENSITIVE MATERIALS

**AMENDMENT UNDER 37 C.F.R. § 1.111**

Commissioner For Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**MAILING CERTIFICATE UNDER 37 C.F.R. §1.8(a)**

I hereby certify that the above correspondence is being deposited with the U.S. Postal Service with sufficient postage as First Class Mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on 3-22-05.

  
Ann Trent

Dear Sir:

Responsive to the Office Action mailed December 22, 2004, in connection with the above identified application, Applicants respectfully submit the following amendments and remarks.